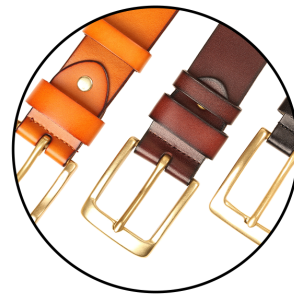


STAR-J1000

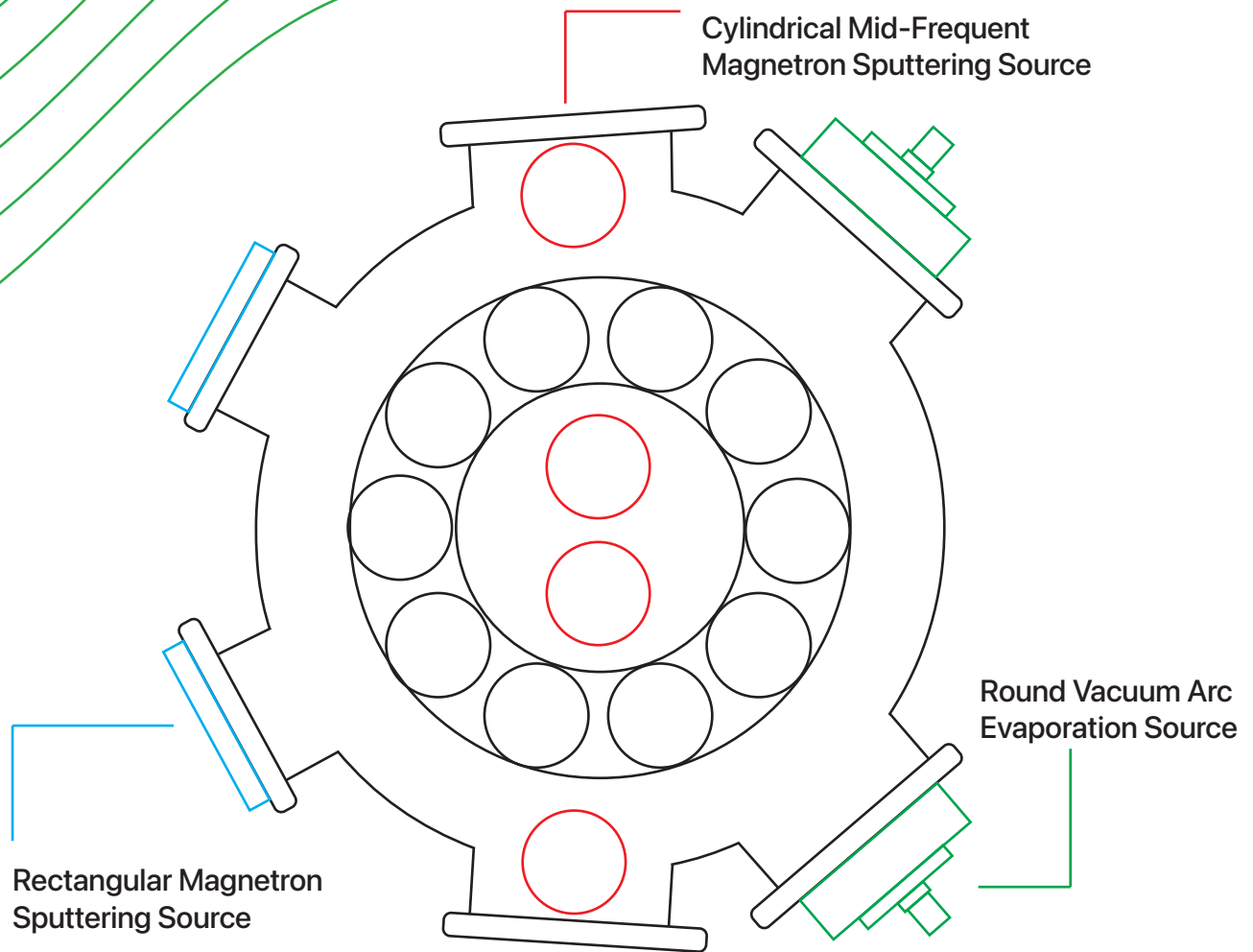
Jewelry PVD Coating System

J-Series
*Designed for
Jewelry Coatings*



The STAR-J1000 unlocks endless possibilities for vibrant and stunning jewelry surface enhancement





SYSTEM SPECIFICATIONS

Chamber Size	Φ1000 x 1040 mm Φ39.4" x 40.9"	Technology	Vacuum Arc + Sputtering
Effective Plasma Zone	Φ600 x 700mm Φ23.6" x 27.6"	Round Vacuum Arc Source	5 sets Φ95 mm
Footprint	L 4,000 x W 3,000 x H 2,000 mm 157.5" x 118.1" x 78.7"	Cylindrical Sputtering Source	4 targets Φ70 x 970 mm
Precious Metals	Gold, Silver	Rectangular Sputtering Source	2 sets 90 x 875 mm